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Correction: Fabrication of poly-crystalline Si-based Mie resonators *via* amorphous Si on SiO₂ dewetting

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Correction for 'Fabrication of poly-crystalline Si-based Mie resonators *via* amorphous Si on SiO₂ dewetting' by Meher Naffouti, *et al.*, *Nanoscale*, 2016, **8**, 2844–2849.

The authors wish to amend the following reference citations in the original manuscript:

- On page 1 of the manuscript, in the sentence beginning “State-of-the-art MRs have...”, reference 14 in the phrase “nanosphere lithography¹⁴” should be reference 12 and reference 13 in the phrase “Fano-like lineshapes¹³” should be reference 11
- On page 2 of the manuscript, in the sentence beginning “As an example...”, the phrase “in ref. 10” should read “in ref. 13”
- On page 2 of the manuscript, in the sentence beginning “The disordered spatial...”, the citation to reference 14 in the phrase “high reflectivity mirrors¹⁴” should be reference 12
- On page 4 of the manuscript, in the sentence beginning “This was shown in...”, the citation to reference 23 should be for reference 22

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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